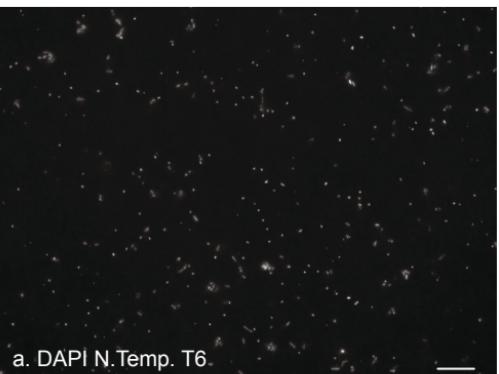


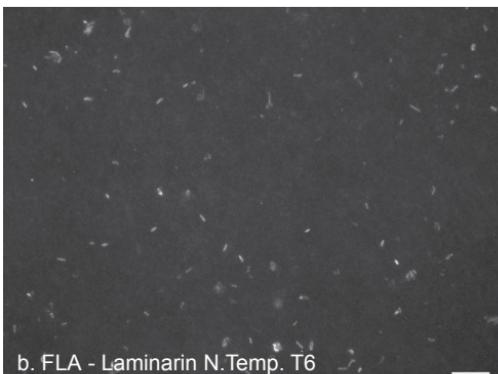
DAPI (365 nm laser, 30ms exposure time)

Substrate (470 nm laser, 300ms exposure time)

Laminarin incubation

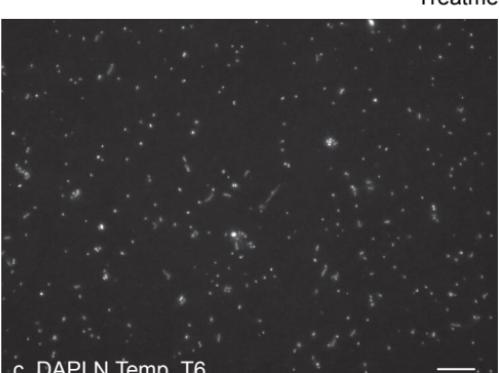


a. DAPI N.Temp. T6



b. FLA - Laminarin N.Temp. T6

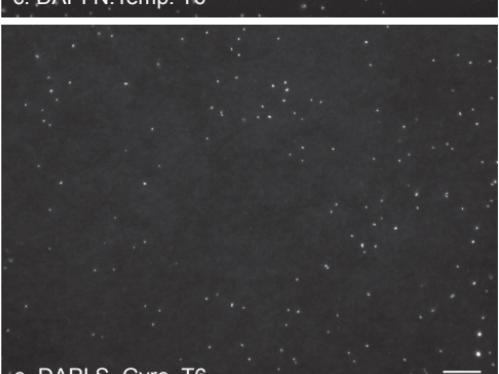
Treatment control



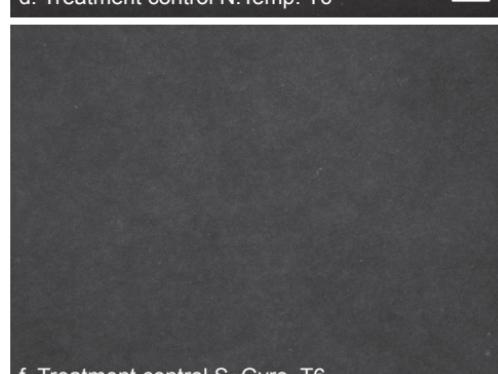
c. DAPI N.Temp. T6



d. Treatment control N.Temp. T6



e. DAPI S. Gyre. T6

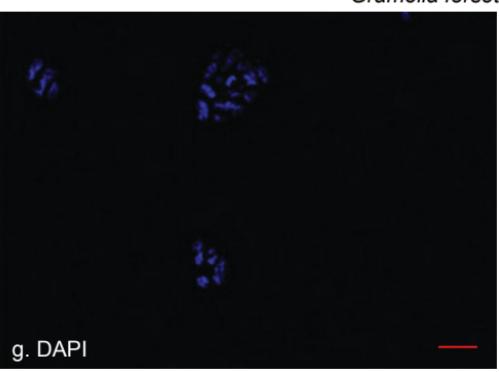


f. Treatment control S. Gyre. T6

DAPI (365 nm laser, 20ms exposure time)

Substrate (470 nm laser, 200ms exposure time)

*Gramella forsetii* FA fixed control



g. DAPI



h. FLA - laminarin